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PATENT NUMBER and  
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10025304	FILING DATE 12/19/2001	CLASS 438	SUBCLASS 2822	GAU 2822	EXAMINER J. P. ALL
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**\*\*CONTINUING DATA VERIFIED:**

NO

**\*\* FOREIGN APPLICATIONS VERIFIED:**

NO

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>	ATTORNEY DOCKET NO 01-377/LS11P180
Foreign priority claimed <input type="checkbox"/> yes <input checked="" type="checkbox"/> no			
35 USC 119 conditions met <input type="checkbox"/> yes <input checked="" type="checkbox"/> no			
Verified and Acknowledged Examiners's initials			
TITLE : Method of preventing resist poisoning in dual damascene structures			

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

<b>NOTICE OF ALLOWANCE MAILED</b>		<b>CLAIMS ALLOWED</b>	
		Total Claims	Print Claim for O.G.
Assistant Examiner		<b>DRAWING</b>	
		Sheets Drwg.	Figs. Drwg.
Primary Examiner		Print Fig.	
PREPARED FOR ISSUE		Application Examiner	
<input type="checkbox"/> <b>TERMINAL DISCLAIMER</b>		<b>WARNING:</b> The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368, Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.	

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